

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Patent No. : 7,393,613  
Application No. : 10/791,763  
Applicant : Wolfgang Dettmann et al.  
Confirmation No. : 4420  
Issued : July 1, 2008  
Customer No. : 054500  
Docket No. : 3000.0036C  
Title : Set of At Least Two Masks for the Projection of Structure Patterns

**ATTN: Certificate of Correction Branch**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**TRANSMITTAL LETTER**

Sir:

Transmitted herewith is a Certificate of Correction (1 page).

It is believed that no fees are required at this time, as the errors in the Official Letters Patent were on the part of the U.S. Patent and Trademark Office.

Respectfully submitted,

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